

Temperature dependent Investigations of Dark Currents of SiPM

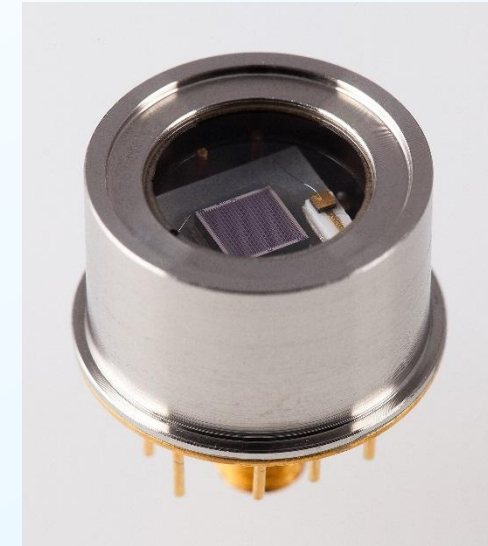
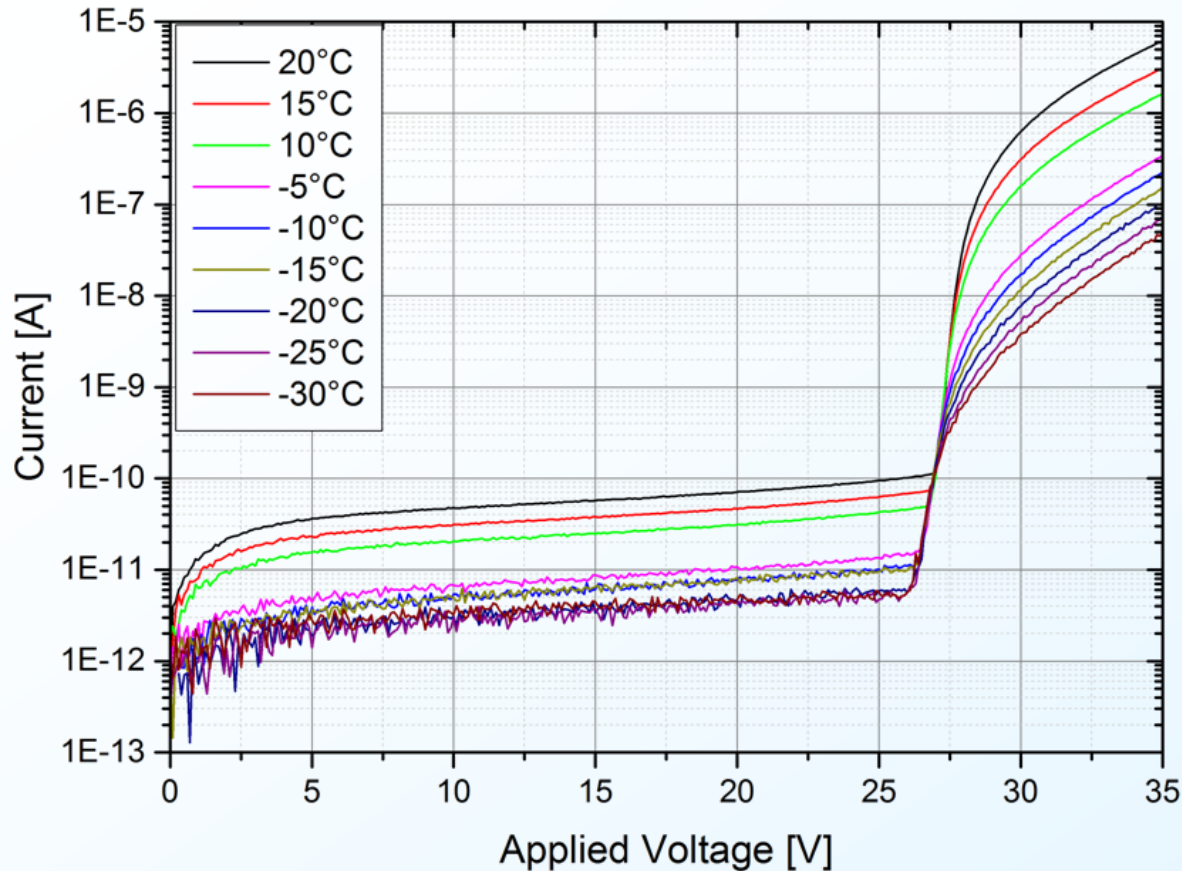
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- Goal of this work:**
- reduction of dark count rate of Silicon Photomultipliers
 - gain initial information on dark generation and extract contributions to dark current

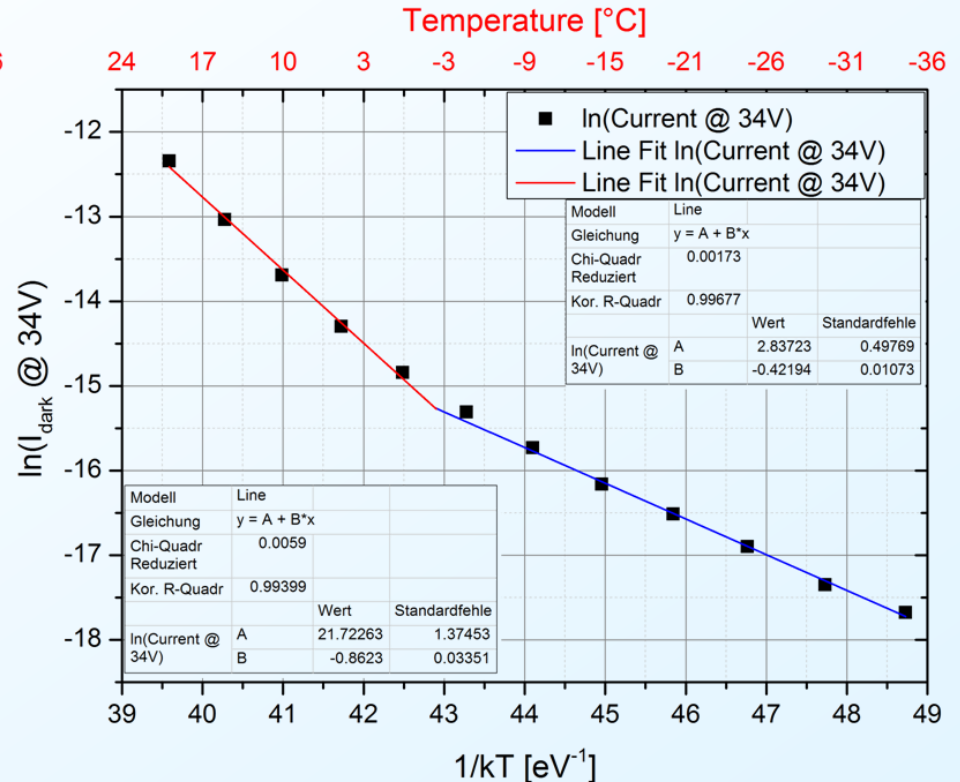
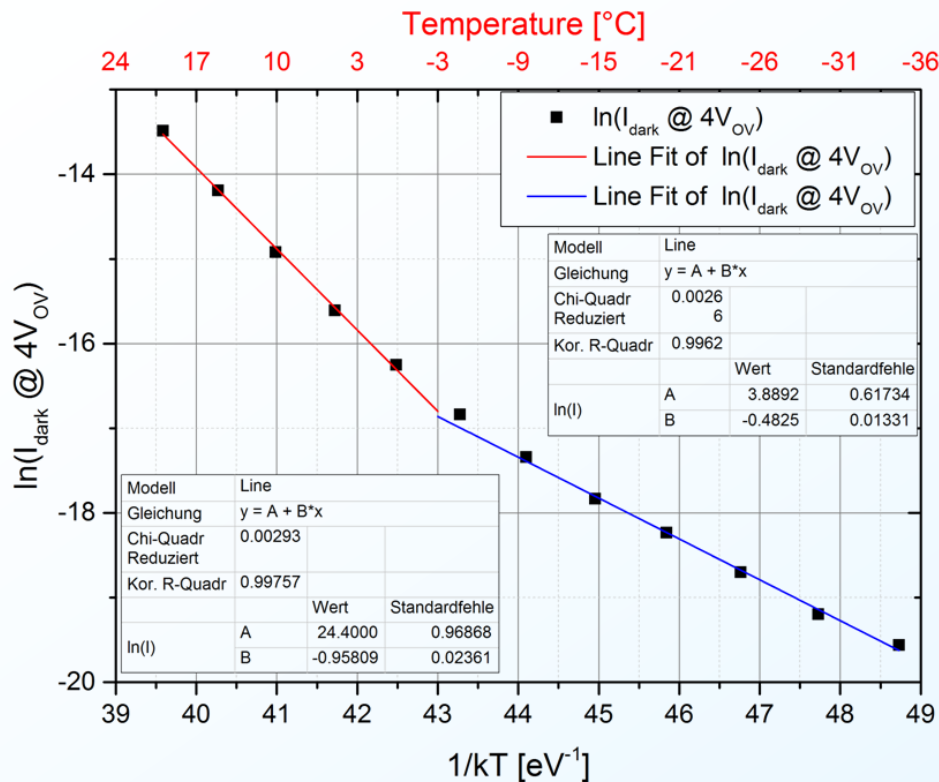
- General approach:**
- activation energies determined from T dependencies are expected to be a good indicator of physical mechanisms
 - conventional methods of extraction of E_{act} at fixed voltages/overvoltages may not be suitable
 - effects dependent on voltage and overvoltage cannot be separated

- Proposed method:**
- independent measurements of photo- and dark-response
 - separation of overvoltage dependent responsivity and voltage dependent high-field effects
 - find expression for field-independent generation component

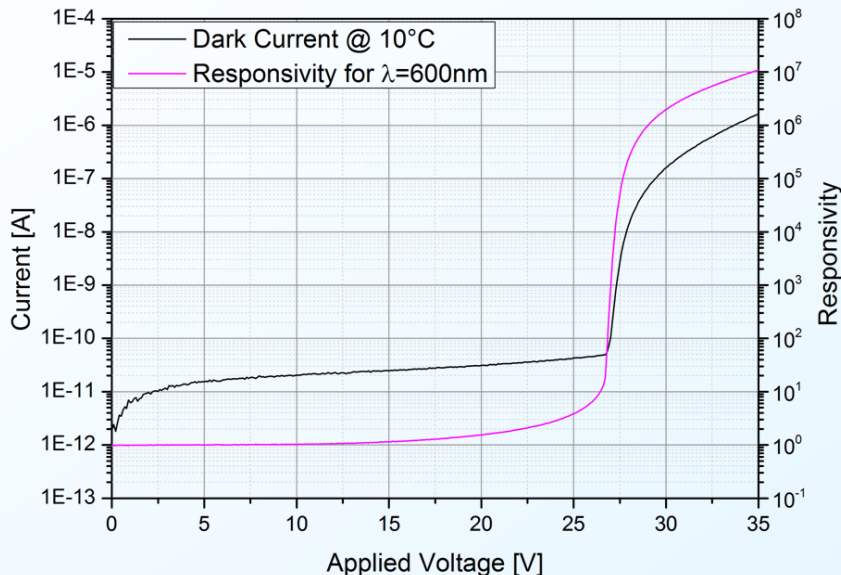
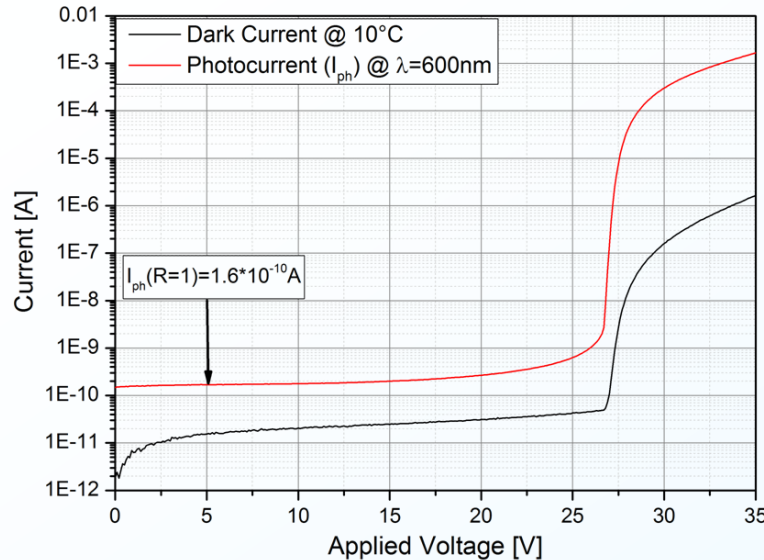


KETEK 3x3 mm² in a TO8

- temperature dependent investigations were performed in a range from 20°C to -30°C
- the measurements were executed on a KETEK 3x3mm² SiPM which was mounted on a Peltier element and evacuated in a TO8 module



- conventional method as proposed in *R. Pagano et al.; „Dark Current in Silicon Photomultiplier Pixels: Data and Model“; IEEE Transactions on Electron Devices; Vol.59 NO. 9; 2012* is not suitable here
- E_{act} can not be attributed to a certain mechanism



- dark and illuminated data was taken
- assumption of an equal responsivity R , for electrons originating from dark generation and photoelectrons

$$\rho(T, V, V_{OV}) := \text{Response}$$

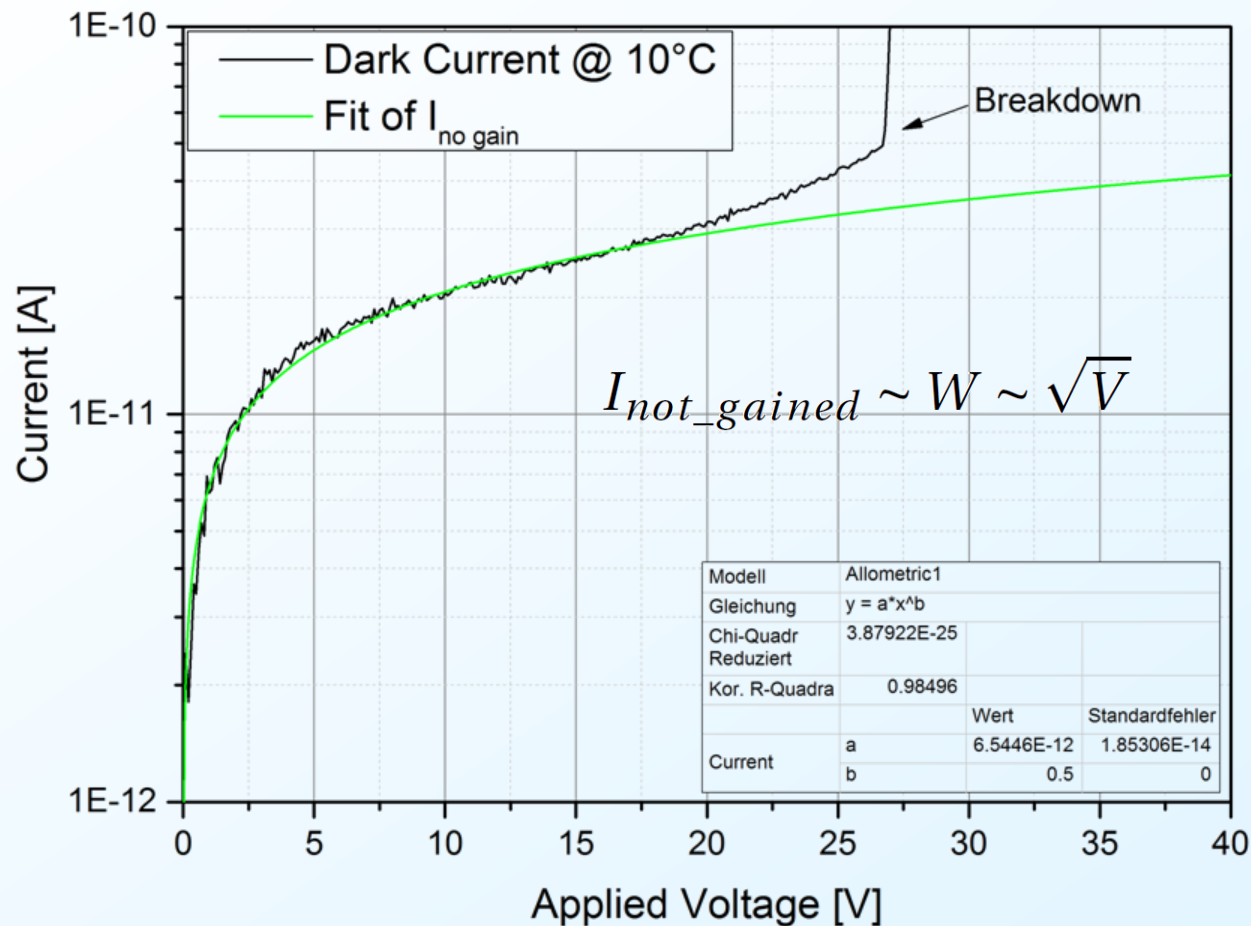
$$R(V_{OV}) := \text{Responsivity}$$

$$R_{dark}(V_{OV}) \approx R_{ph}(V_{OV}) = \frac{\rho_{ph}(V_{OV})}{\rho_{ph}(V_0)}$$

$$\rho_{dark}(T, V, V_{OV}) = \rho_{ini}(T, V) \cdot R_{ph}(V_{OV})$$

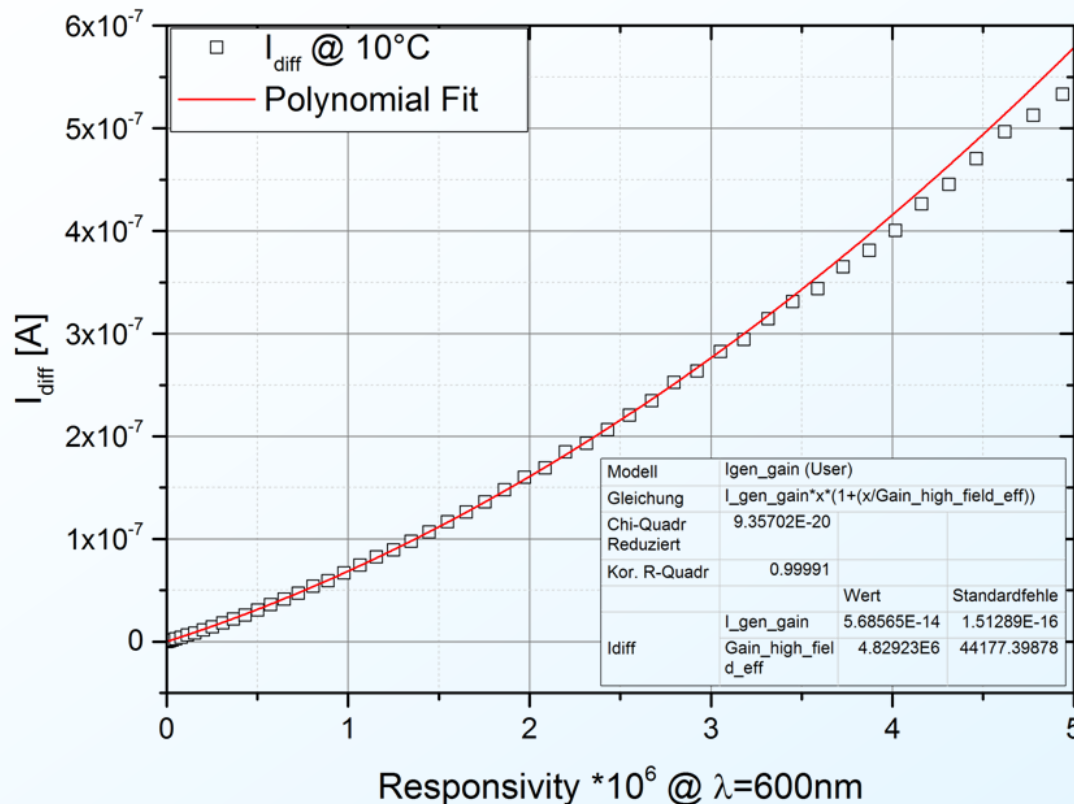
- in general this approach is applicable for any Response ρ , e.g. I_{dark} or DCR

$$I_{dark}(T, V, V_{OV}) = I_{not_gained}(T, V) + I_{gained}(T) \cdot F_{high_field}(V) \cdot R_{ph}(V_{OV})$$



$$I_{\text{dark}}(T, V, V_{\text{OV}}) = I_{\text{not_gained}}(T, V) + I_{\text{gained}}(T) \cdot F_{\text{high_field}}(V) \cdot R_{\text{ph}}(V_{\text{OV}})$$

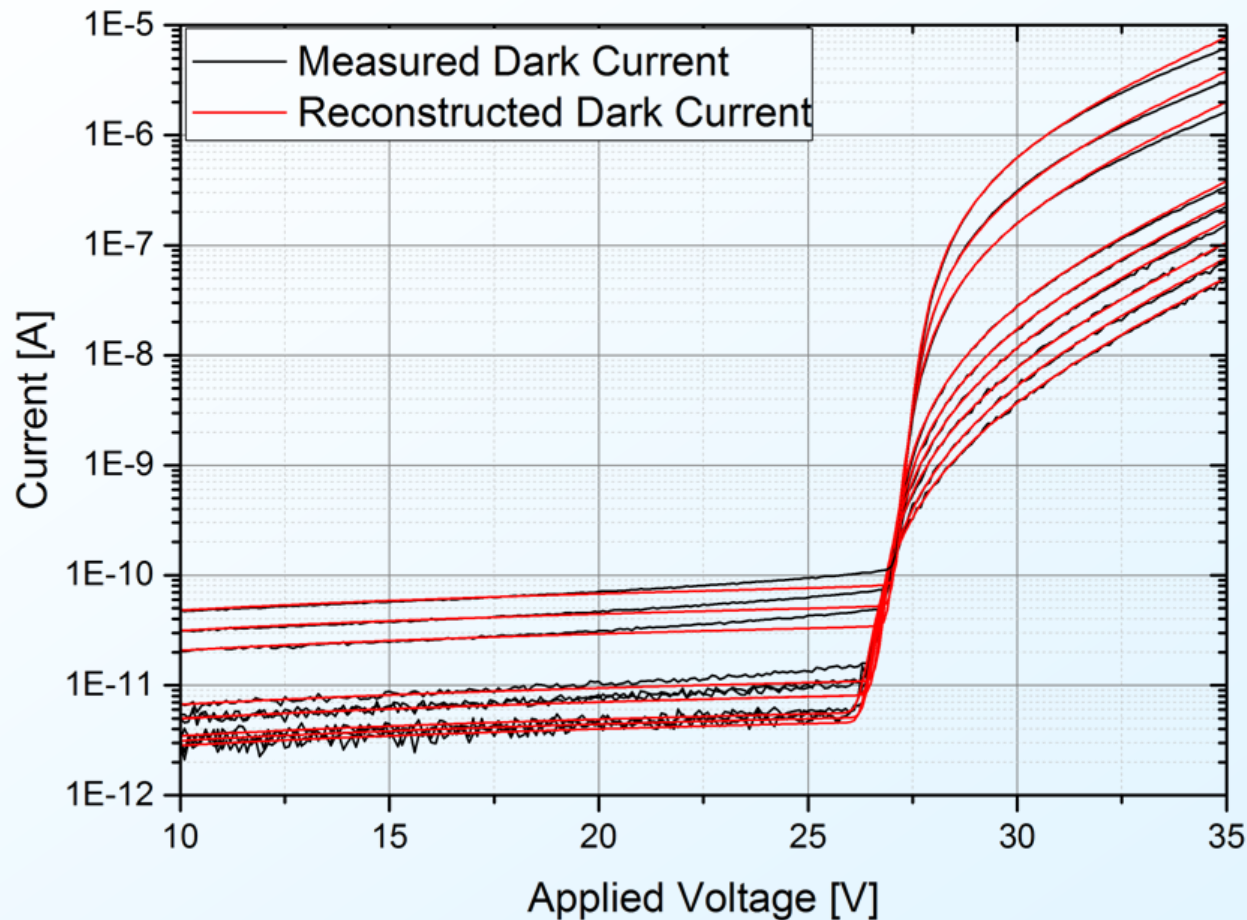
- in order to determine the multiplied component, the difference between the measured dark current and $I_{\text{not_gained}}$ is investigated as a function of the responsivity

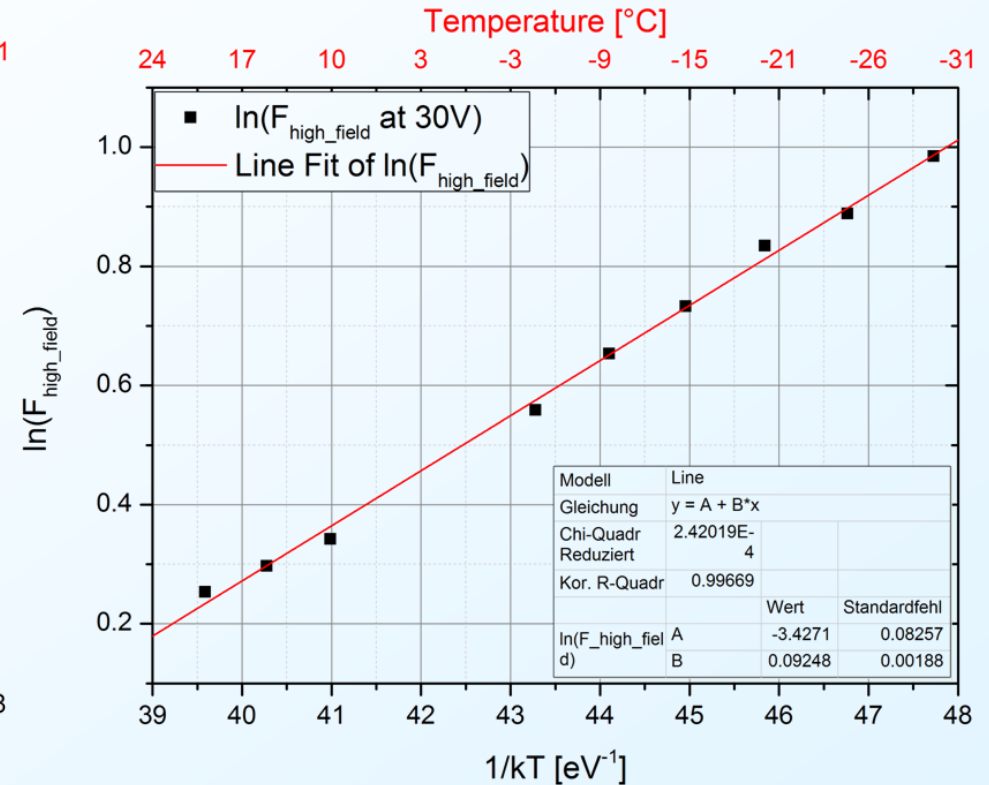
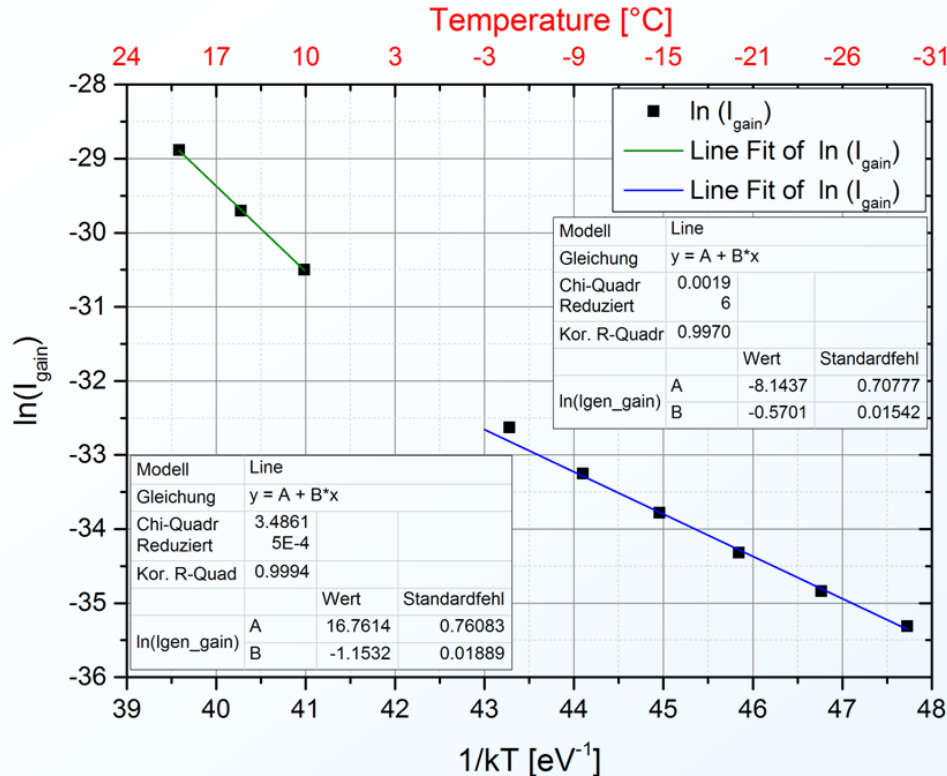


$$I_{\text{diff}}(R_{\text{ph}}) = I_{\text{gained}} \cdot R_{\text{ph}} \left(1 + \frac{R_{\text{ph}}}{R_{\text{eff}}} \right)$$

- I_{diff} could be described with a parabolic function in good agreement in the range between $R=0$ to $R=4 \times 10^6$
- I_{gained} represents initial charge carriers generated or provided to the multiplication region

$$I_{dark}(T, V, V_{OV}) = I_{not_gained}(T, V) + I_{gained}(T) \cdot F_{high_field}(V) \cdot R_{ph}(V_{OV})$$





- I_{gained} shows two activation Energies $E^1_{\text{act}} \approx E_g$ and $E^2_{\text{act}} \approx E_g/2$
- $F_{\text{high_field}}$ lowers the effective activation energy by ΔE_{act}
- ΔE_{act} is close to expected value for Poole-Frenkel effect

Results so far

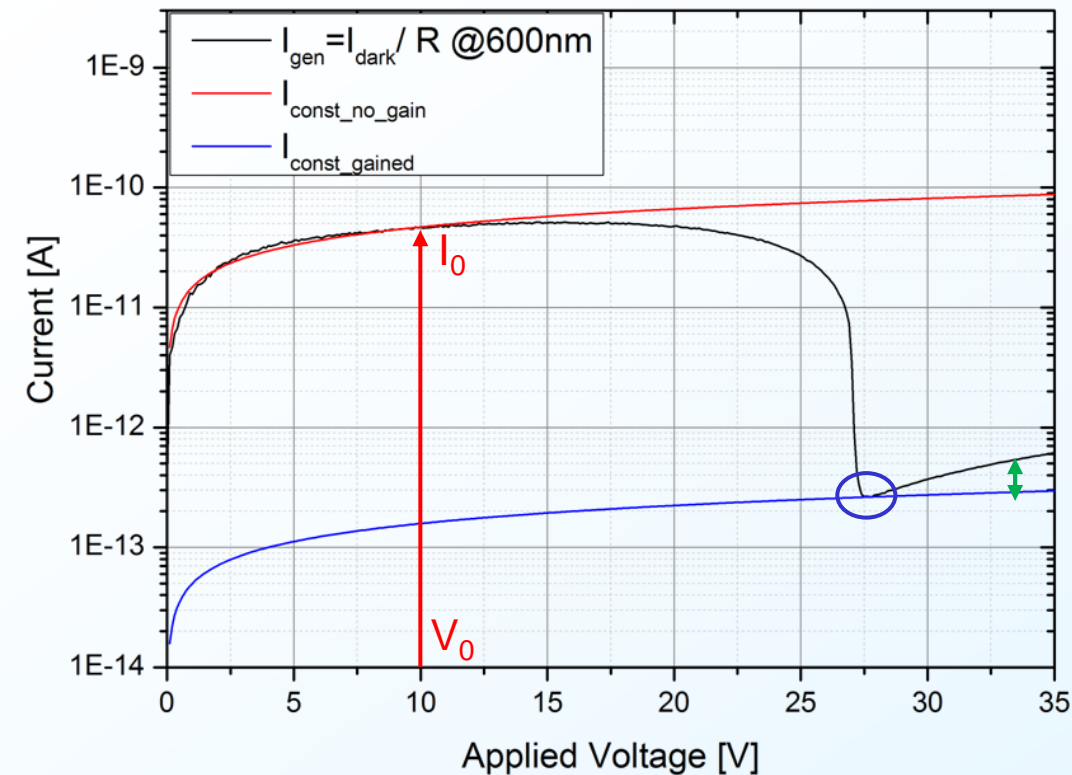
- the chosen model for dark current could describe the measured data to a sufficiently precise level
- field-enhanced effects could be separated from generation components
- the extracted activation energies indicate that dark currents at $T > -5^{\circ}\text{C}$ are diffusion dominated, whereas currents at $T < -5^{\circ}\text{C}$ are dominated by generation (KETEK devices)

Further investigations

- confirmation of model for different type of devices
- identification of micro-cell regions as origin for diffusion currents
- change technological process in order to reduce DCR

Thank you for the attention

Additional Slides



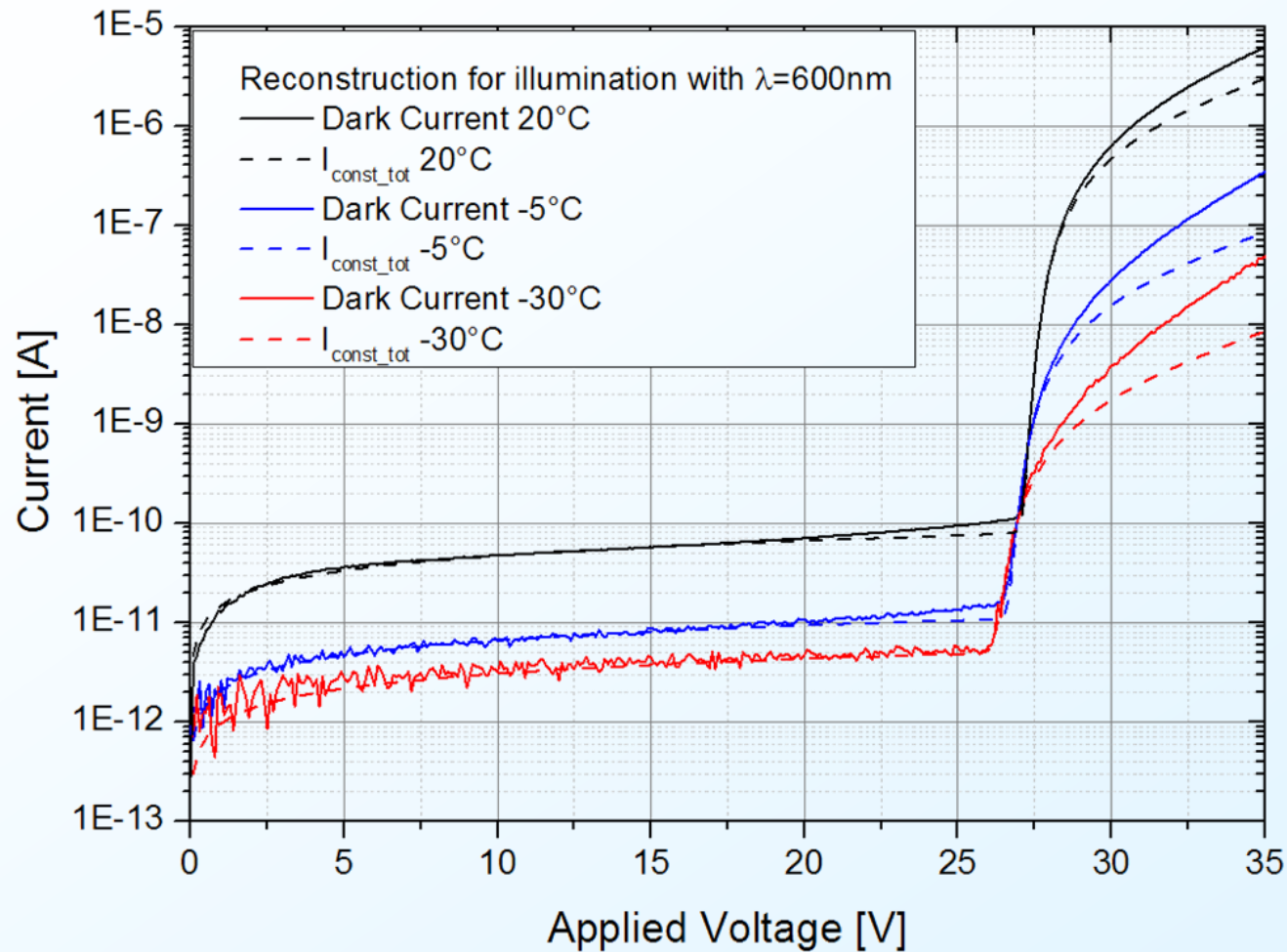
- analysing I_{gen} consisting of a multiplied and non-multiplied component

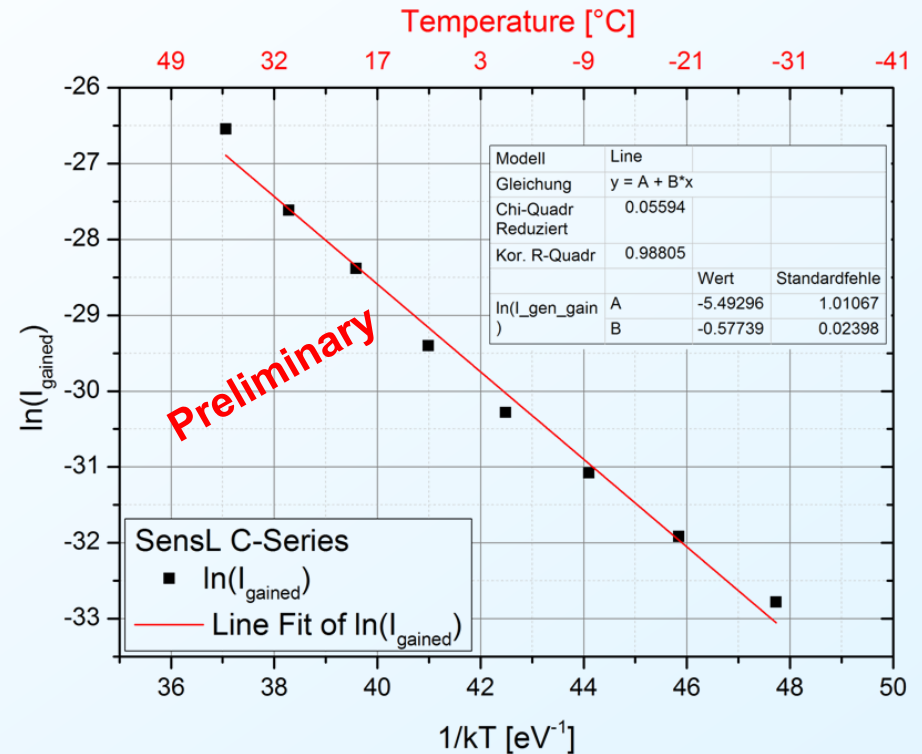
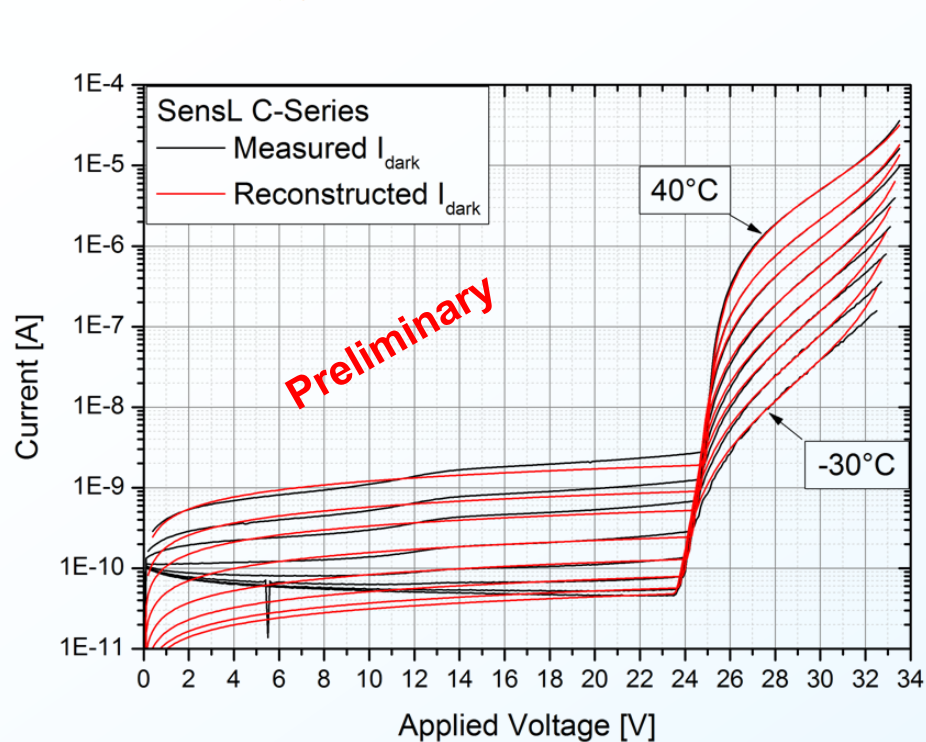
$$I_{\text{dark}} = I_{\text{not_gained}} + I_{\text{gained}} \cdot R_{\text{ph}}$$

$$I_{\text{not_gained}} = I_0 \cdot \sqrt{\frac{V}{V_0}}$$

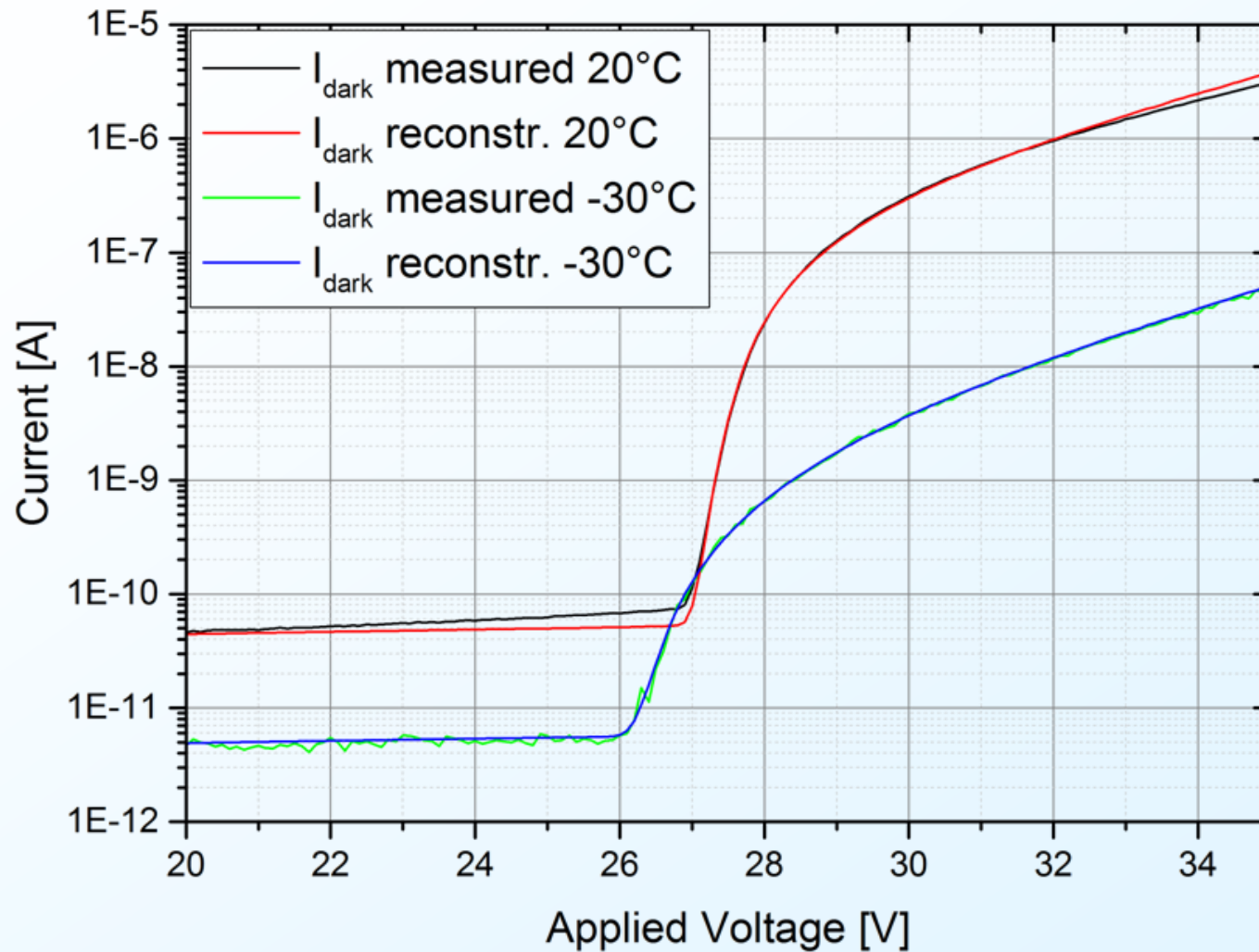
- I_{gained} is assumed to be a small fraction of $I_{\text{not_gained}}$

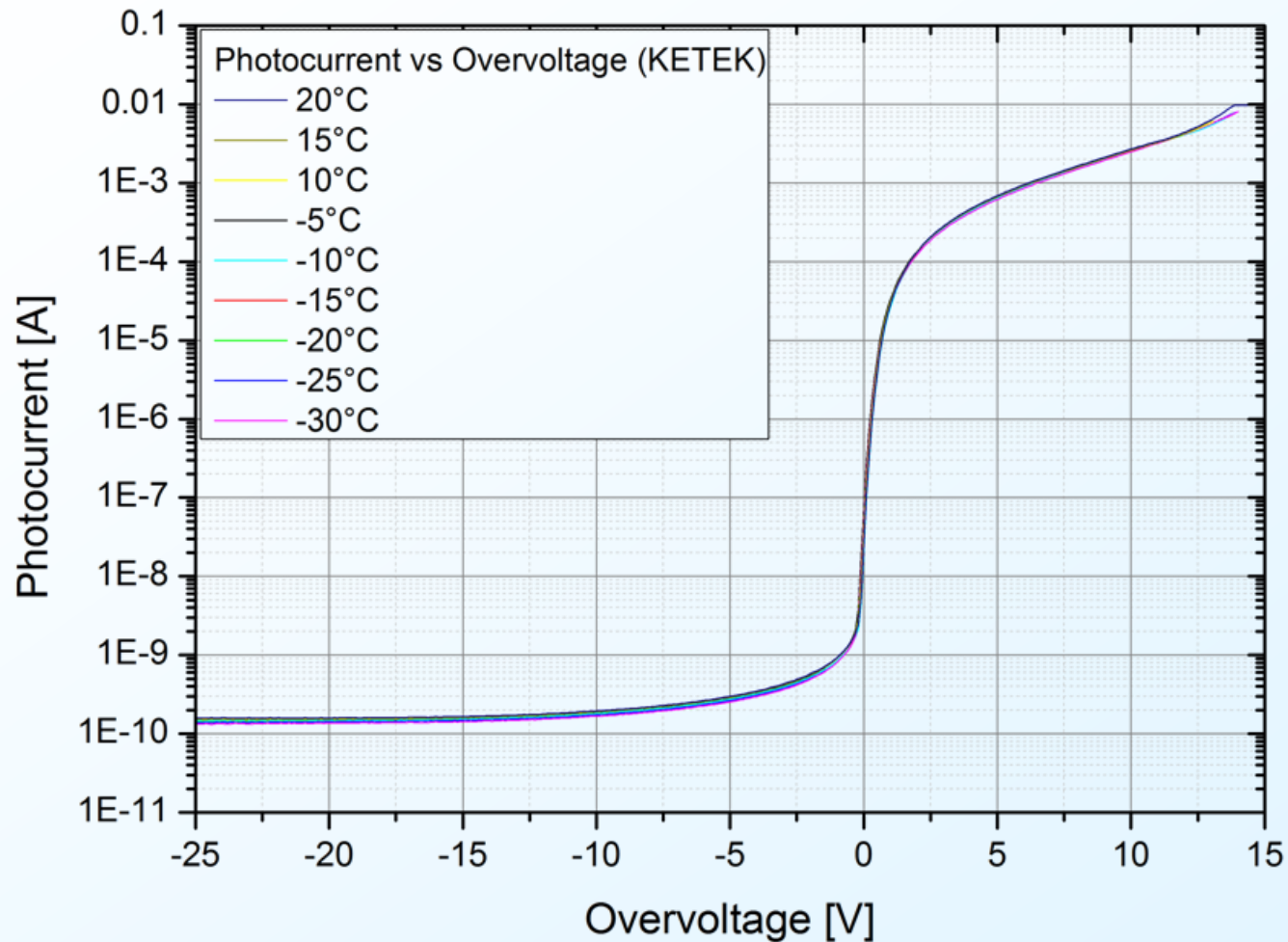
$$I_{\text{gained}} = \delta \cdot I_{\text{not_gained}}$$

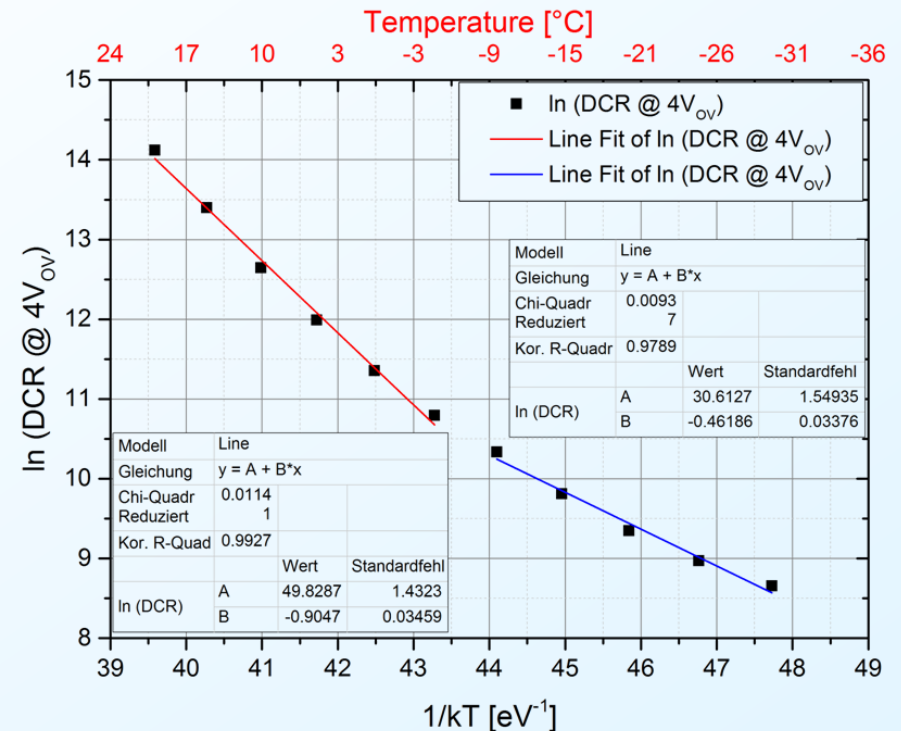
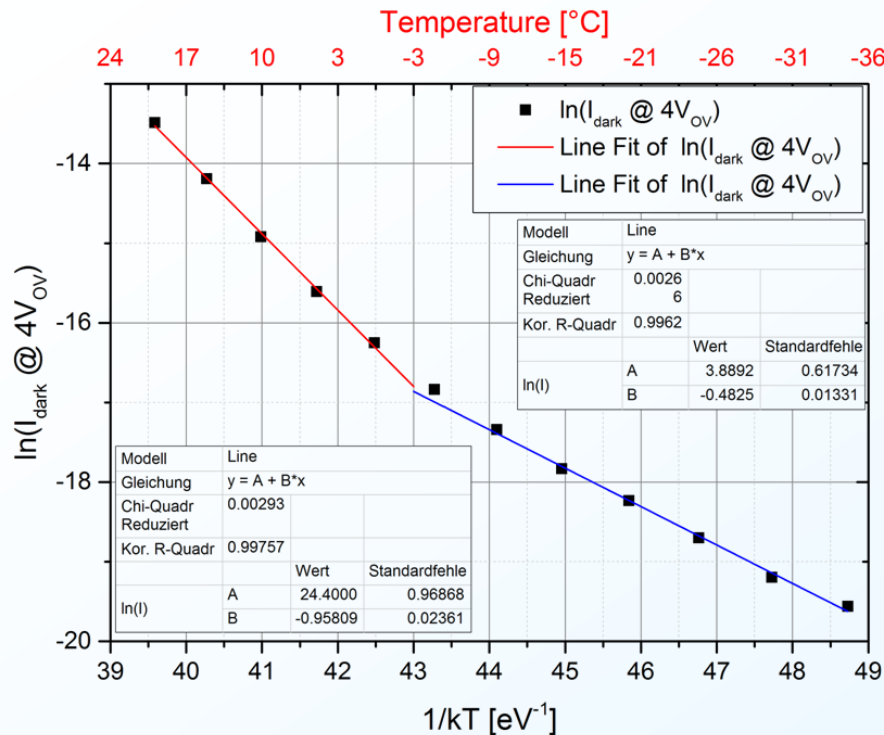




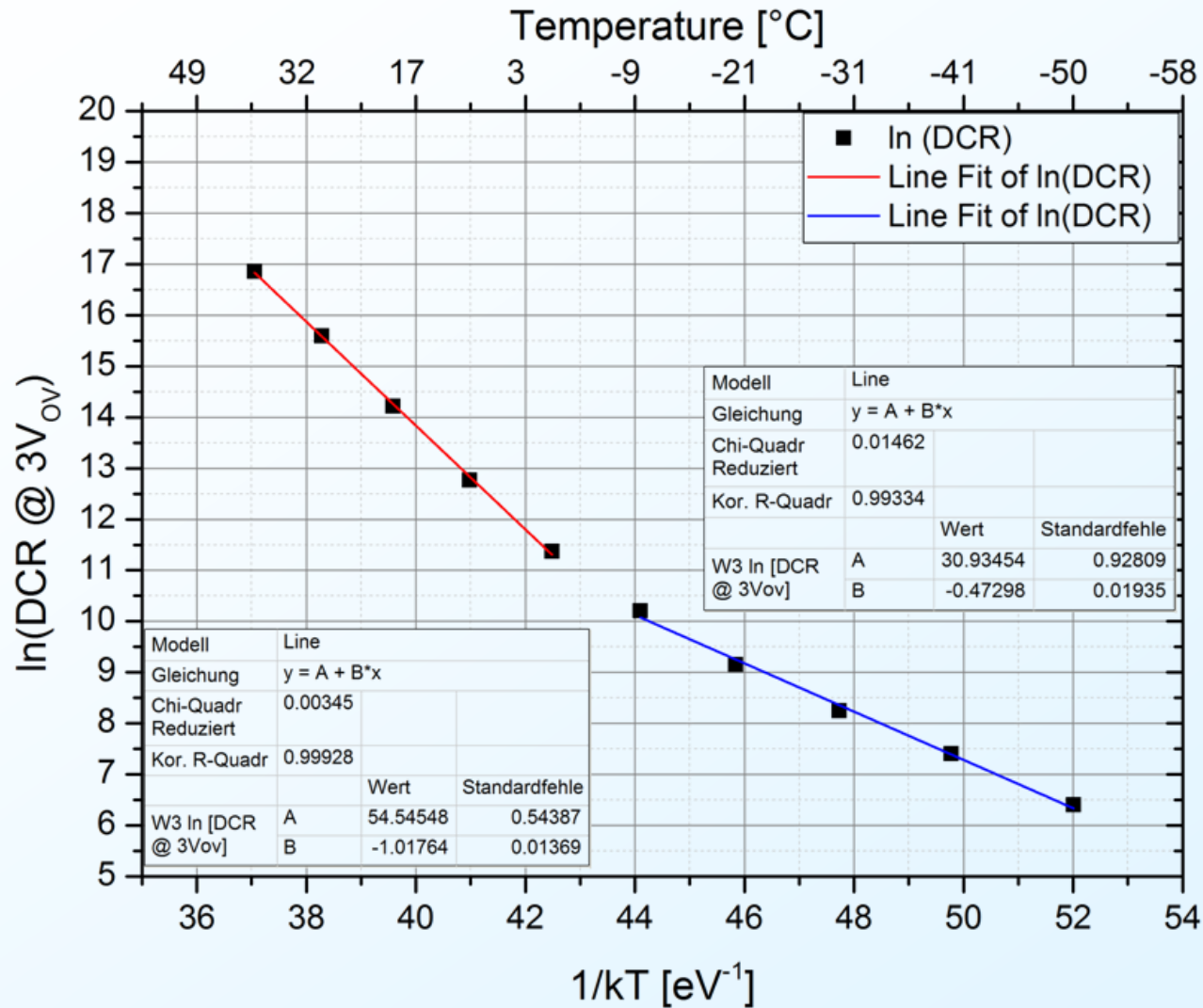
- a 3x3mm² C-Series device from SensL was investigated for comparison
- only one slope could be observed in the Arrhenius plot
- E_{act} of (0.57 ± 0.02) eV is attributed to generation current
- the contribution of diffusion current is expected to be suppressed for this device

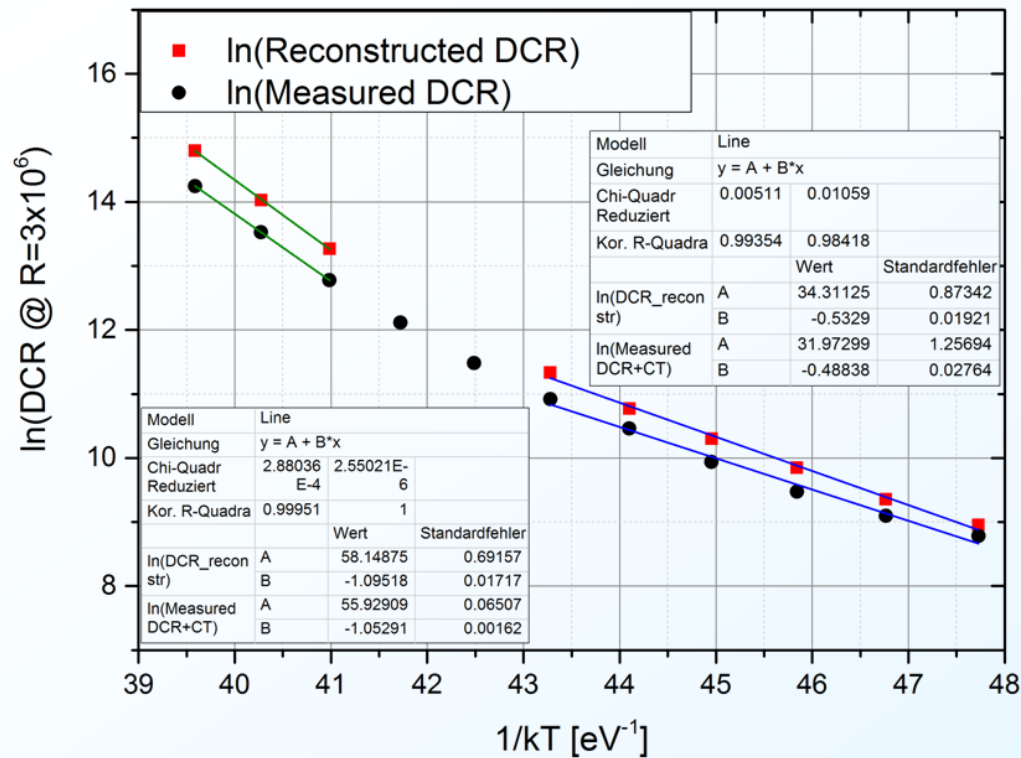






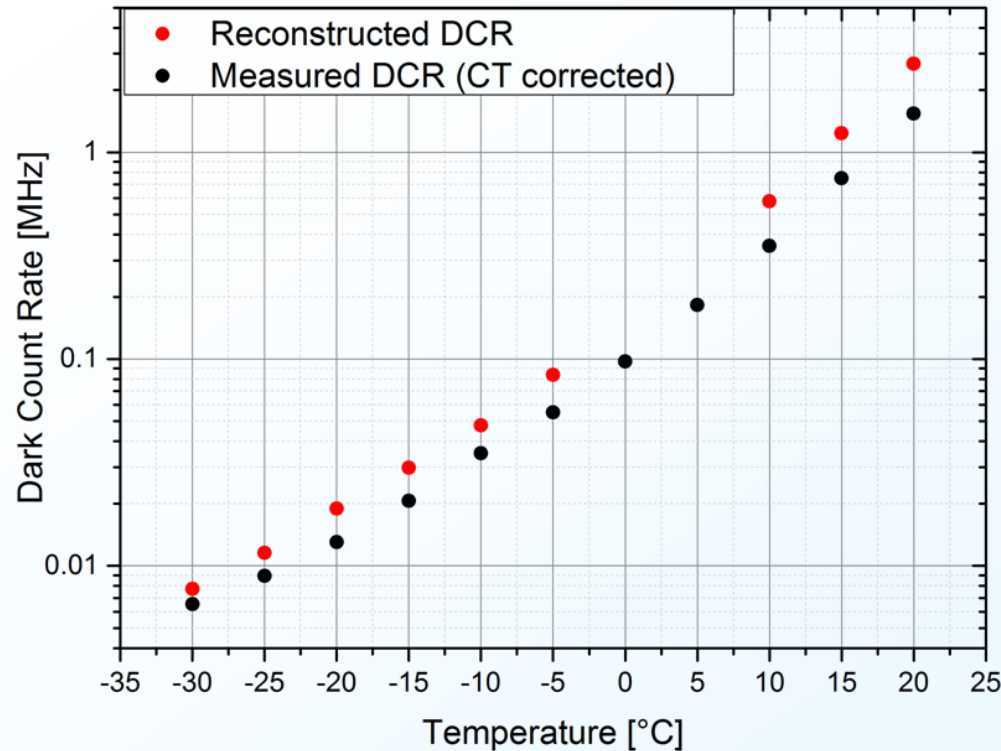
- the extracted E_{act} directly from $I_{dark}(T)$ and $DCR(T)$ at a fixed overvoltage show slightly different values, but agree within the uncertainties
- E_{act} from „raw“ data is an indicator for physical mechanisms
- for a precise analysis, a more advanced analysis is necessary





$$DCR = \frac{I_{gain} \cdot F_{high_field}}{q}$$

- E_{act} extracted from DCR is a sum of field-independent I_{gained} and field-dependent F_{high_field}
- $DCR_{measured}$ and $DCR_{reconstr}$ show comparable E_{act} within the uncertainties
- this result is an indicator of the parameter fit quality
- the measured DCR has to be additionally corrected for avalanche triggering probability



$$DCR = \frac{I_{gain} \cdot F_{high_field}}{q}$$

- $DCR_{reconstr}$ overestimates $DCR_{measured}$
- internal generation rate of dark events is expected to be higher than DCR
- the measured DCR has to be additionally corrected for avalanche triggering probability